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ABSTABLET OF THE DESCLOSURE

Integrated Circuit Arrangement and Method for the Manufacture Thereof

A doped region (3) is provided in a substrate (1). A plane with conductive useful structures (71) and a conductive filler structure (72) is arranged at the surface of the substrate (1). The conductive filler structure (72) is conductively connected to the doped region (10, 3). In this way, a charging of the conductive filler structure (72), which is provided for improving the planarity of the circuit arrangement and has no circuit oriented function, is avoided.

Figure 6

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